



App. No.: 09/296,835 Docket No.: M4 0319/P319
Inventor: Ronald A. Weimer, et al.
Title: FABRICATION OF DRAM AND OTHER
SEMICONDUCTOR DEVICES WITH AN INSULATING FILM
USING A WET RAPID THERMAL OXIDATION PROCESS
Sheet 1 of 7

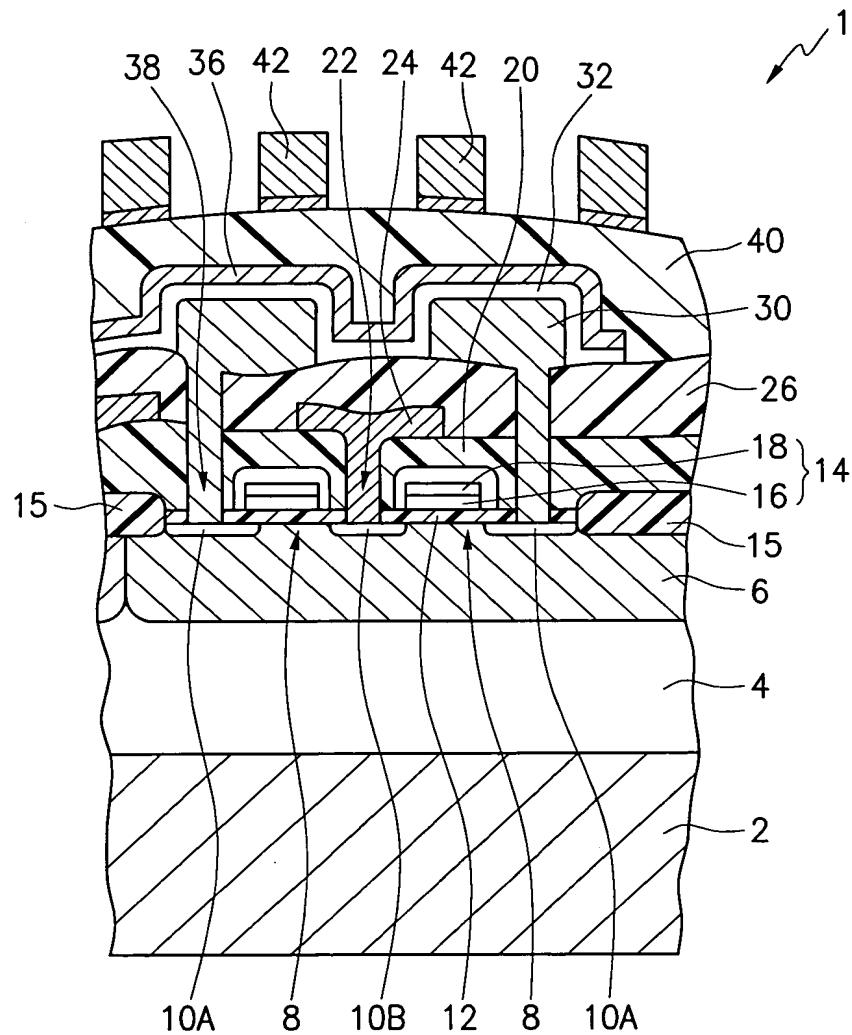


FIG. 1



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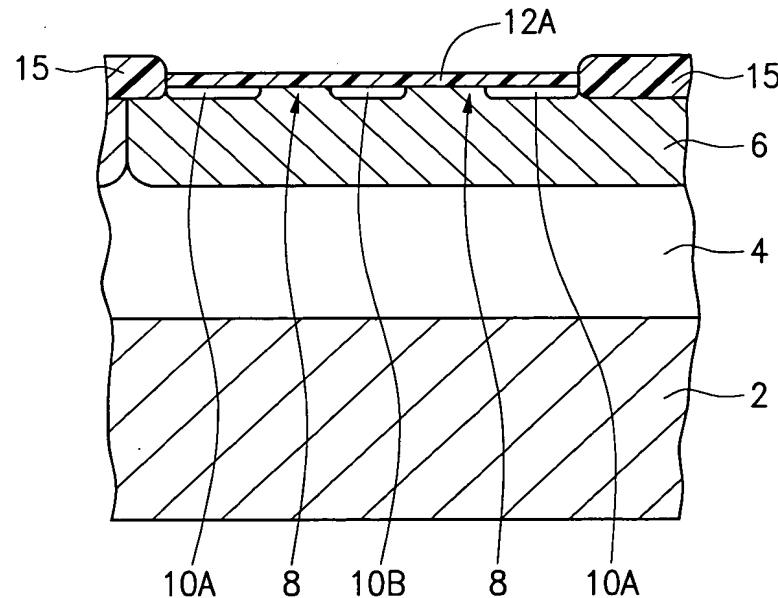


FIG. 2

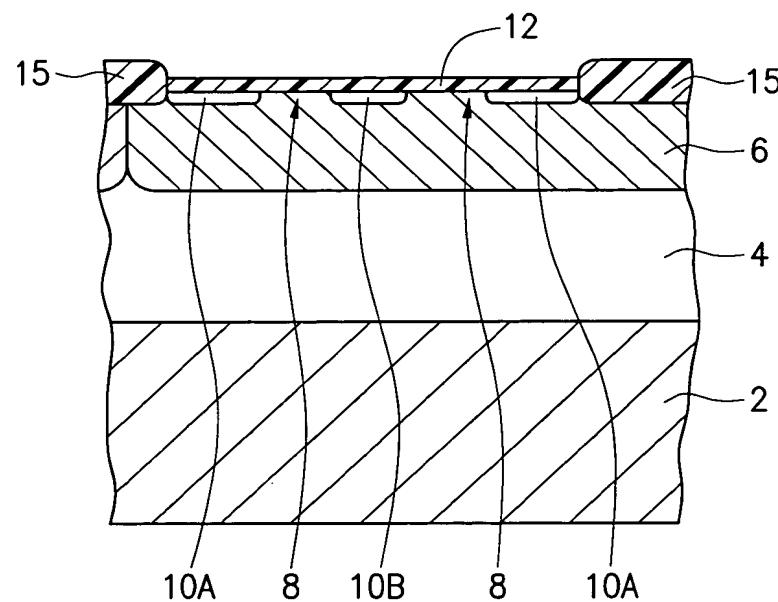


FIG. 3



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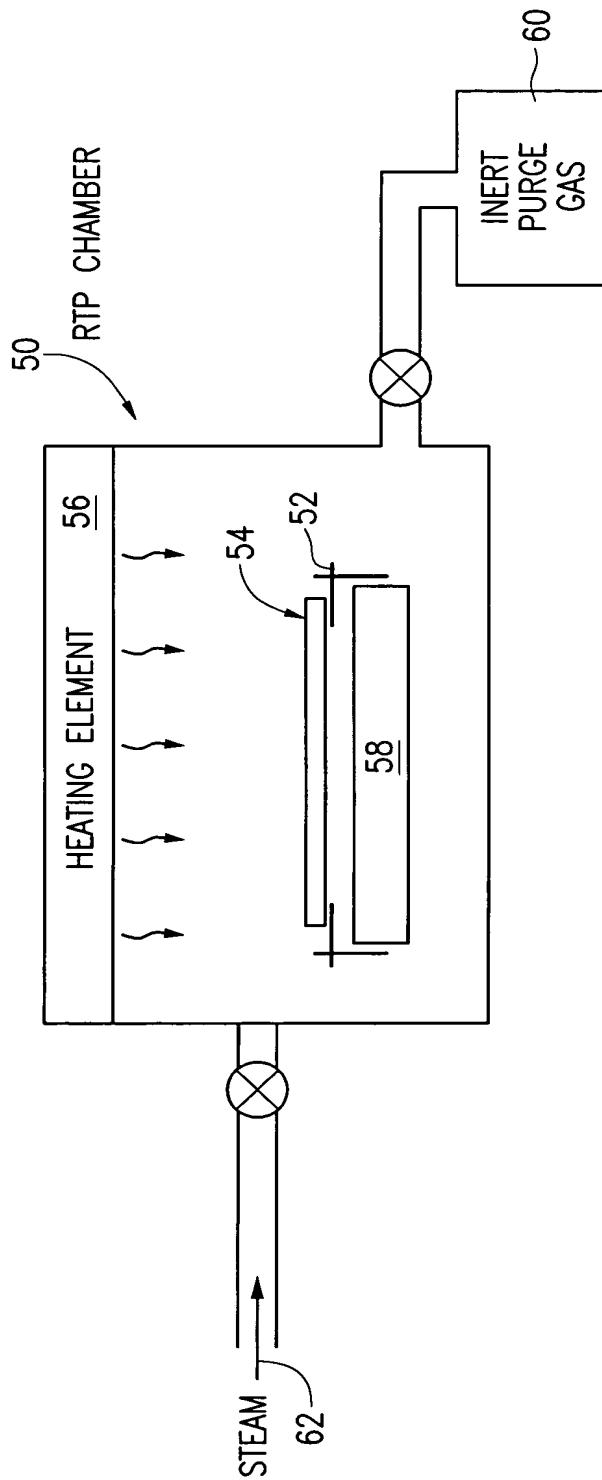


FIG. 4



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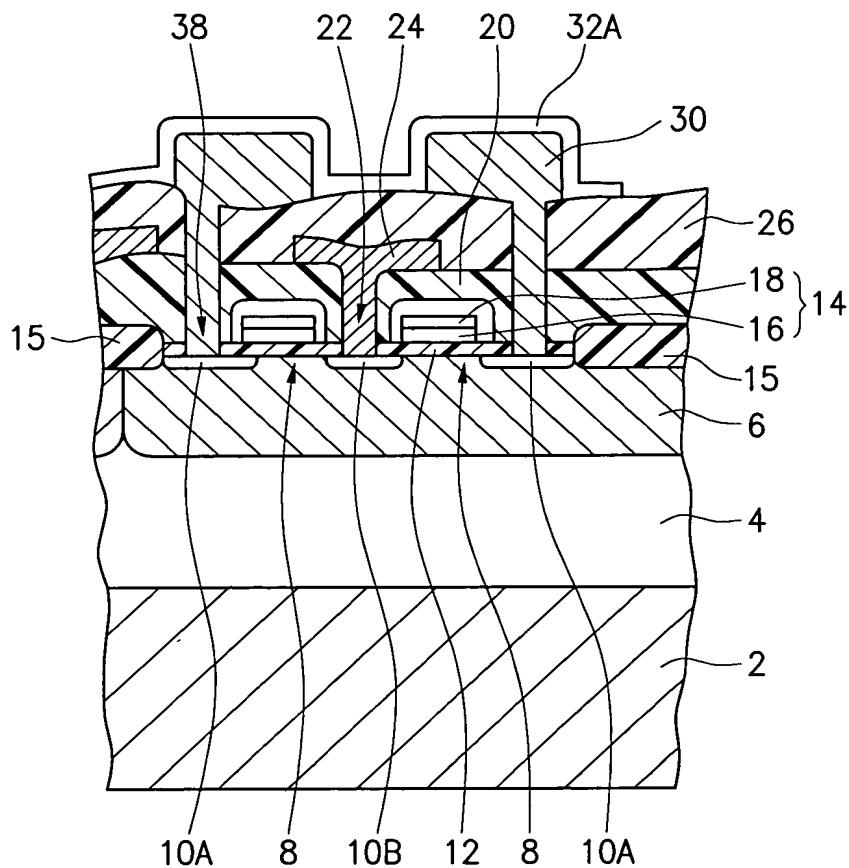


FIG. 5



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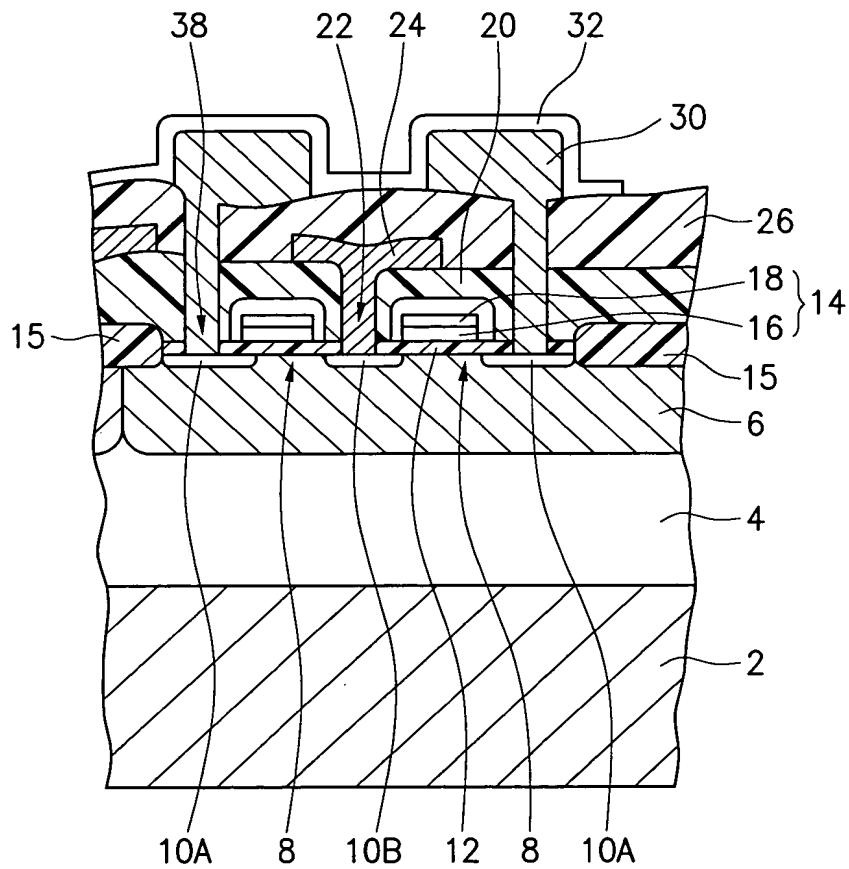


FIG. 6



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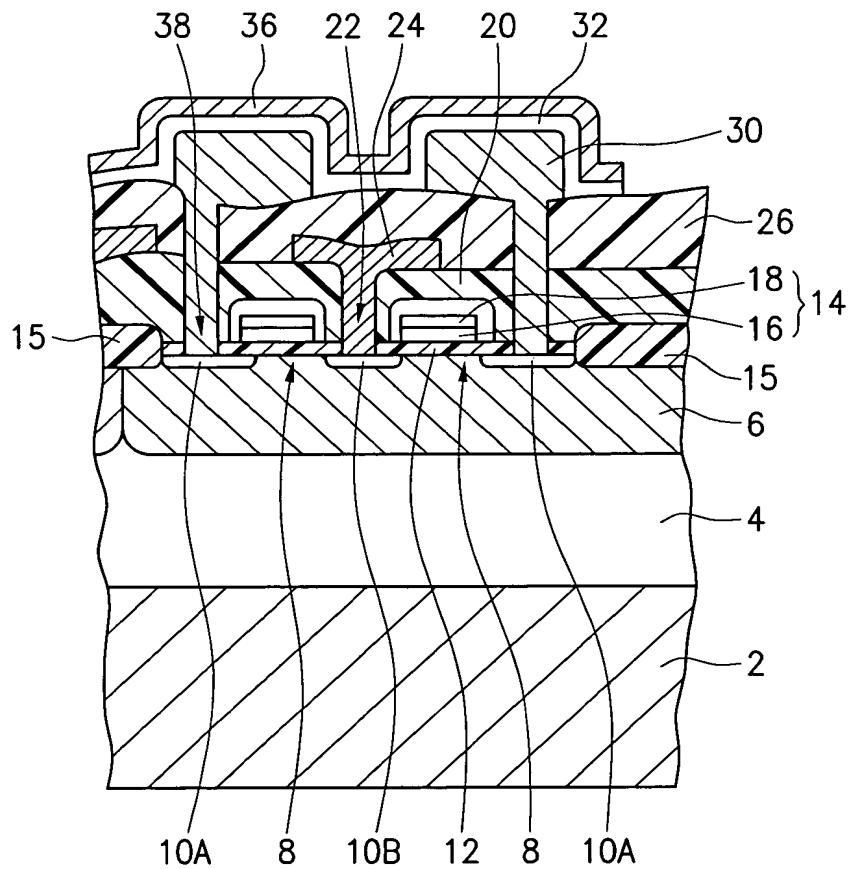


FIG. 7



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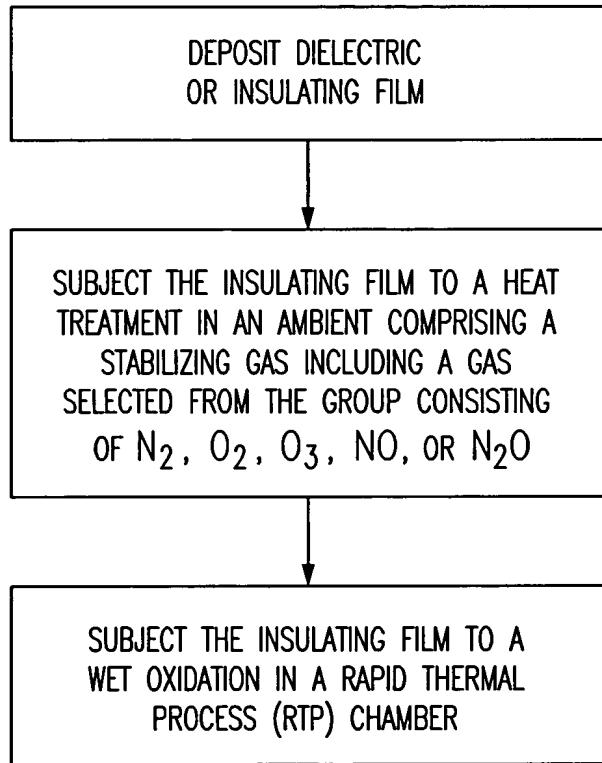


FIG. 8